



Synthesis of LiVO_3 thin films by spray pyrolysis technique

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ABSTRACT

Lithium metavanadate thin films were successfully deposited on glass substrates by spray pyrolysis technique at substrate temperature of 250 °C. 0.2 M spraying solution was prepared by mixing appropriate volumes of LiCl and VCl_3 solutions. Structural, vibrational and optical properties of deposited film are discussed. X-ray diffraction and micro-Raman spectroscopy have revealed that LiVO_3 with monoclinic symmetry was obtained. Optical properties of thin film were studied from transmission measurement in the range UV–Visible.

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1. Introduction

Li-V-O system has been widely studied due to its applications in rechargeable lithium batteries, solid fuel cells or electrochromic display devices [1–4]. Orthovanadates of the type $\text{M}_3(\text{VO}_4)_2$ (M: Ca, Sr, Ba) have excellent luminescence properties which are enhanced when doped with suitable rare-earth element, and find application as laser host materials [5]. Metavanadate of the type MVO_3 (M: Li, Na, K, Rb, Cs) undergoes a ferroelectric (space group $C_c(C_2^d)$) to paraelectric (C_2/c) irreversible phase transition as function of temperature [6,7]. This transition is associated with very slight structural changes due to reorientations of the displacement ellipsoids of the lithium atoms [7].

LiVO_3 powdered or crystal samples were prepared by direct solid state reaction between stoichiometric proportions of Li_2CO_3 and V_2O_5 [7–9]. Coexistence of LiVO_3 and other phases such as Li_3VO_4 and $\text{Li}_x\text{V}_2\text{O}_5$ has been observed in lithium oxide vanadium powders prepared by the reaction of aqueous H_2O_2 solution with lithium and vanadium alkoxides, $\text{LiO-n-C}_3\text{H}_7$ and $\text{VO(O-i-C}_3\text{H}_7)_3$ [10]. Excessive starting Li/V molar ratio lead to the formation of LiVO_3 , this result has been observed in the synthesis of $\text{Li}_{1+x}\text{V}_3\text{O}_8$ by sol–gel route at low temperature [11]. It has to be noticed that not having find studies concerning LiVO_3 thin films.

The aim of this work is to investigate X-ray diffraction, scanning electron microscopy, Raman and UV–Visible spectroscopy

of LiVO_3 thin film prepared, in the first time, by spray pyrolysis technique.

2. Experimental

LiVO_3 thin films were obtained on glass substrates by spray pyrolysis technique. The spray solution 0.2 M, was prepared by mixing appropriate volumes of VCl_3 and LiCl solutions (80% LiCl + 20% VCl_3), bidistilled water was used as solvent. The substrate temperature was fixed at 250 °C and controlled through a thermocouple (Chrome–Nickel). Compressed air of pressure 2 bars has been used as a carrier gas, the solution flow is 5 cm^3/min and spray nozzle to heating plaque distance of 27 cm. The color of as-prepared films not having undergone treatment is light blue.

Structural characterization has been carried out at room temperature in the $\theta - 2\theta$ scan mode using a Rigaku Miniflex diffractometer (CuK_α radiation, $\lambda = 1.5405 \text{ \AA}$). Morphology of as-deposited thin film was observed using a Jeol JSM 5800 scanning electron microscope.

Raman spectroscopy measurements were performed at room temperature in a backscattering microconfiguration using the 514.5 nm line from an Ar-ion laser focused on the surface as a spot of 1 μm in diameter and with a power density of $\sim 3 \text{ mW}/\text{cm}^2$. The scattered light was analyzed with a Jobin Yvon T64000 spectrometer, equipped with a liquid nitrogen cooled CCD detector. The spectrometer provided a wave number resolution better than 3 cm^{-1} .

Optical measurement of the transmittance was carried out in the wavelength range (200–900 nm) using a UV–Visible JASCO type V-570 double beam spectrophotometer.

3. Results and discussion

3.1. Structural properties

X-ray diffraction pattern of spray pyrolysed thin film is given in Fig. 1. The pattern exhibits several peaks in different directions indicating the polycrystalline nature of thin film. A good agreement

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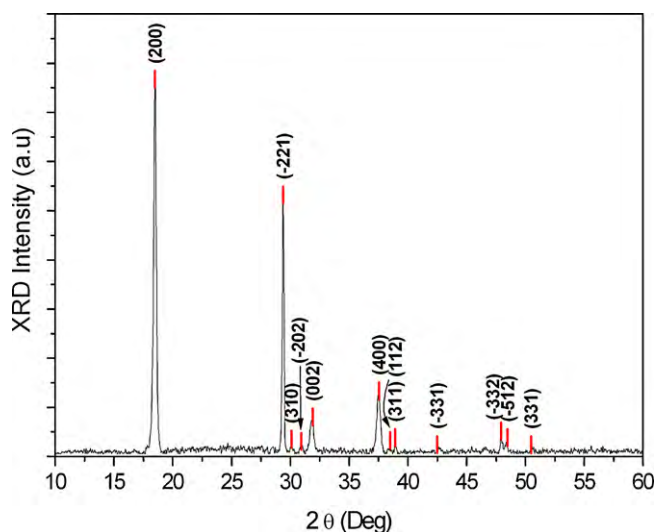


Fig. 1. X-ray diffraction pattern of spray pyrolysed LiVO_3 .

is observed between the inter-reticular distances of obtained sample and those of ICDD card no. 73-1030 corresponding to the LiVO_3 with monoclinic symmetry. Only the polycrystalline phase of LiVO_3 was identified and no impurity was detected.

The peaks are indexed in comparing our experimental data (measured inter-reticular distances d_m and their diffracted intensities I_m) with the ICDD X-ray powder data file.

For monoclinic system, the inter-reticular distances d_{hkl} are evaluated by the following relation:

$$d_{hkl} = \frac{\sin \beta}{\sqrt{(h^2/a^2) + (l^2/c^2) + ((k^2 \sin^2 \beta)/b^2) - ((2hl \cos \beta)/(ac))}} \quad (1)$$

with $a \neq b \neq c$, $\alpha = \gamma = \pi/2$ and $\beta > \pi/2$.

In this relation (h, k, l) are miller indices of reflector plans appearing on the diffraction spectra and d_{hkl} their inter-reticular distances. Lattice parameters were refined with the CELREF program [12], the obtained values are summarized in Table 1. A very weak expansion of LiVO_3 lattice is observed and can be explained by the deposition conditions.

For the estimation of crystallite size the Sherrer formula is used [13]:

$$G = \frac{k\lambda}{D \cos(\theta)} \quad (2)$$

where k is the shape factor with value in the neighborhood of 1. D is defined as the full width at half maximum of more intense diffraction peak, λ is the $\text{CuK}\alpha$ wavelength and θ is the Bragg angle; the grain size is about 41 nm.

The surface morphology of the as-deposited film was studied using SEM and is shown in Fig. 2. It can be learned that, grains with regular shape and narrow lateral size compose the film, a low roughness of the surface is observed. The investigation of surface morphology was achieved without the treatment of the films.

Table 1
Lattice parameters obtained and comparison with literature data.

	a (Å)	b (Å)	c (Å)	β (°)	V (Å ³)
This work	10.22	8.27	5.95	110.91	470.51
ICDD card no. 73-1030	10.18	8.41	5.87	110.83	469.95
[7]	10.16	8.41	5.88	110.50	471.23

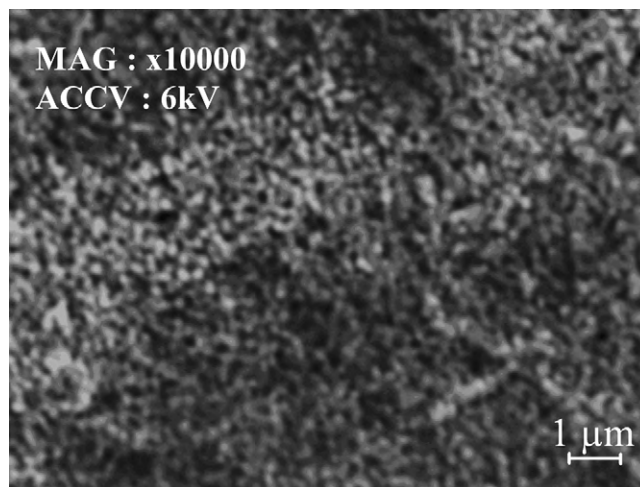


Fig. 2. SEM micrograph of spray pyrolysed LiVO_3 thin film.

3.2. Raman micro-spectroscopy

The crystal structure of LiVO_3 has been determined for the first time by Shannon and Calvo by X-ray single crystal diffraction and has been described as monoclinic structure with space group $C_2/C(C_{2h}^6)$ in which bands of LiO_6 octahedra are linked by chains of VO_4 tetrahedra parallel to the c -axis [7,9].

According to C_{2h} factor group ($k=0$) the crystal modes can be classified as follows:

$$\Gamma_{\text{opt}} = 22A_g + 20B_g + 20A_u + 22B_u \quad (3)$$

All the g modes are Raman active and u modes are Infrared active. Therefore 42 vibration modes are possible in the Raman spectroscopy of LiVO_3 [14].

Raman spectrum, in the range 100–1100 cm^{-1} is shown in Fig. 3. The spectrum clearly resembles that of LiVO_3 , given in the literature [15]. All the observed Raman bands are listed in Table 2 and assigned in comparing with observed modes of LiVO_3 [14,15], a very good agreement is observed between our result and those of literature. In the high frequency region, the Raman bands are assigned to VO_2 stretching vibrations. The mean V–O distance of 1.65 Å for two exterior oxygen atoms is much shorter than of 1.808 Å for

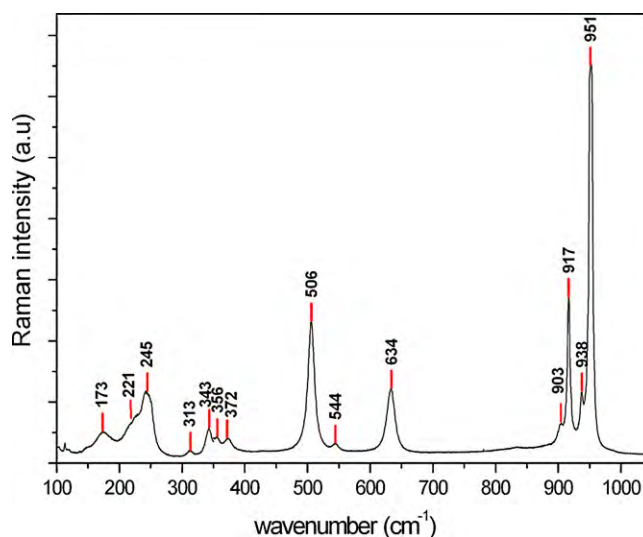


Fig. 3. Raman spectrum in the frequency range 1100–100 cm^{-1} of lithium metavanadate.

Table 2
Experimental frequencies (cm^{-1}) and assignment of the Raman active modes.

This work	Assignment [14, 15]	[15]	[14]
951 (vs)	$\nu_s(\text{VO}_2)$, (exterior)	952	954
938 (w)		939	
917 (s)		912	
903 (sh)	$\nu_s(\text{VO}_2)$, (backbone)	902	902.4
			820.6
			838
			648.9
634 (m)	$\nu_a(\text{VOV})$	640	
			559.9
544 (w)	Mixed $\delta(\text{VOV})$, $\nu(\text{VO}_2)$	540	
506 (s)	$\nu_s(\text{VOV})$	500	
372 (w)	} $\delta(\text{VO}_2)$	379	388.5
356 (w)		359	352.4
343 (w)		339	
		328	326
313 (vw)			265
			267.3
244 (m)	ρ_r, ρ_t, ρ_w , Chain deformations	242	231.3
221 (sh)	$\delta(\text{VOV})$	212	214.3
173 (m)	Lattice mode	185	160

s: strong, m: medium, w: weak, v: very, sh: shoulder, ρ_r, ρ_t, ρ_w : rock, wag, twist motions, δ : bending vibration, ν_s : symmetric stretching vibration, ν_a : asymmetric stretching vibration.

two backbone oxygen atoms [9]. Therefore the very intense Raman band observed at 951 cm^{-1} is assigned to VO_2 vibration involving the exterior oxygen atoms with V–O distance of 1.65 \AA , and the band at 912 cm^{-1} to that involving the backbone oxygen atoms with V–O distance of 1.808 \AA . While those in $500\text{--}650 \text{ cm}^{-1}$ region, are assigned to the VOV vibrations, δVO_2 modes are observed in the 300 cm^{-1} region. The medium band observed at 244 cm^{-1} is related to the rock, wag, twist or deformation motions of the V–O chains and shoulder at about 213 cm^{-1} (Lorentzian fitted value), is assigned to bending vibrations δVOV modes. Below 200 cm^{-1} , the Raman bands are assigned to lattice modes.

3.3. Optical characterization

Optical transmission for lithium metavanadate film measured in the range $300\text{--}900 \text{ nm}$ is shown in Fig. 4a. The film presents absorption edge towards 300 nm and a maximum which reaches 58% . The optical absorption coefficient was evaluated by the approximate relation:

$$\alpha = \frac{1}{d} \ln \frac{1}{T} \quad (4)$$

where T represents the transmission coefficient and d its thickness estimated towards 200 nm . The variation of absorption coefficient, as a function of photon energy is presented in Fig. 4b (curve inserted). The values of α not exceed $8 \times 10^4 \text{ cm}^{-1}$, this result can be explained by the influence of roughness or crystallization of the film.

The inter-band absorption theory shows that the absorption coefficient near the threshold versus incident energy is given by

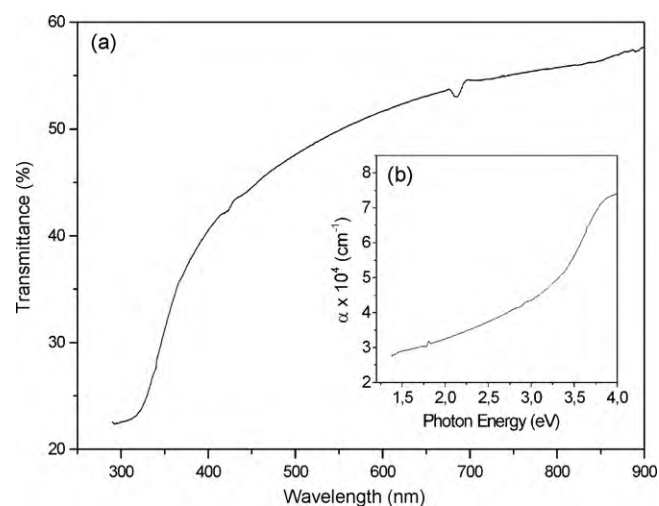


Fig. 4. (a) Transmission spectrum of LiVO_3 thin film and (b) (insert curve) absorption coefficient of LiVO_3 .

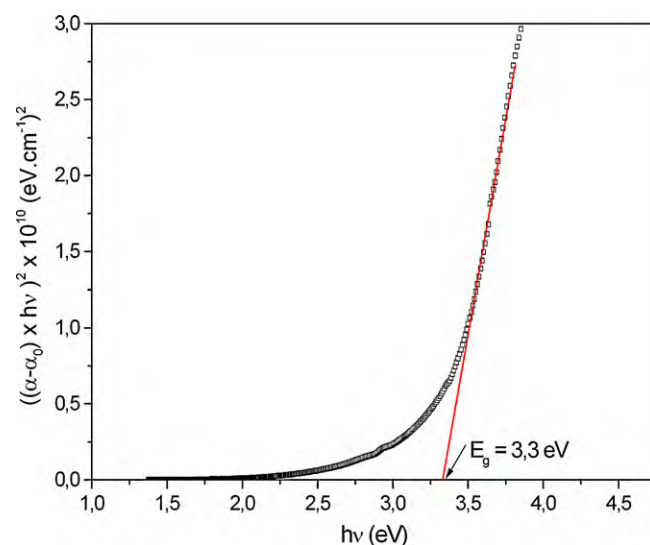


Fig. 5. $((\alpha - \alpha_0)hv)^2$ versus photon energy plot of LiVO_3 thin film.

the following relation [16]:

$$(\alpha hv) = A_n (hv - E_g)^n \quad (5)$$

where A_n is the probability parameter for the transition and E_g the optical gap energy.

For allowed direct transitions the coefficient n is equal to $1/2$ and for indirect allowed transitions $n = 2$.

$((\alpha - \alpha_0)hv)^{1/2}$ do not present a linear character which suggests that LiVO_3 thin films prepared by spray pyrolysis technique have a direct gap. The variation of $((\alpha - \alpha_0)hv)^2$ is shown in Fig. 5, where α_0 characterizes the residual absorption. This curve presents a linear character which suggests that LiVO_3 thin films prepared by spray pyrolysis have a direct gap, the E_g value about 3.3 eV is estimated by extrapolation of linear part of $((\alpha - \alpha_0)hv)^2$ curve to the energy axis.

4. Conclusions

LiVO_3 thin films were prepared in the first time by spray pyrolysis technique. The structural results reveal that the prepared film exhibits a polycrystalline monoclinic structure. The value of average crystalline size is about 41 nm . Raman spectrum is well resolved

and all the Raman frequencies observed, correspond to LiVO_3 and confirm the XRD results. The optical band gap has been found to be 3.3 eV and corresponds to direct allowed transition.

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